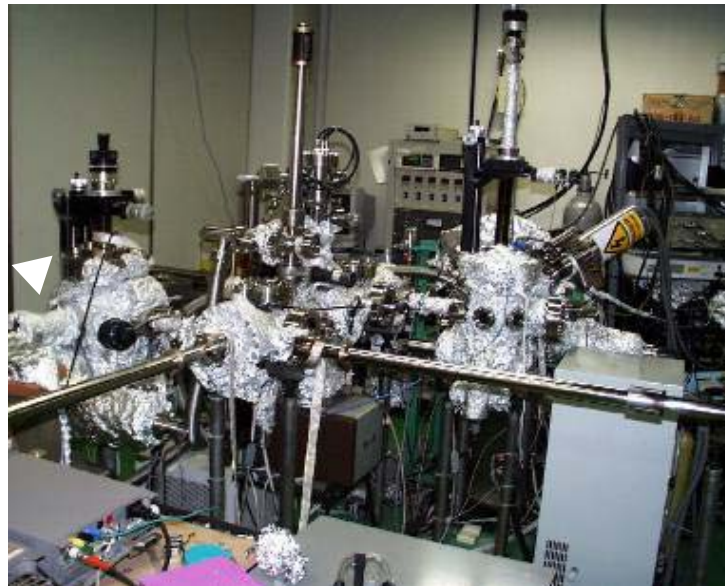
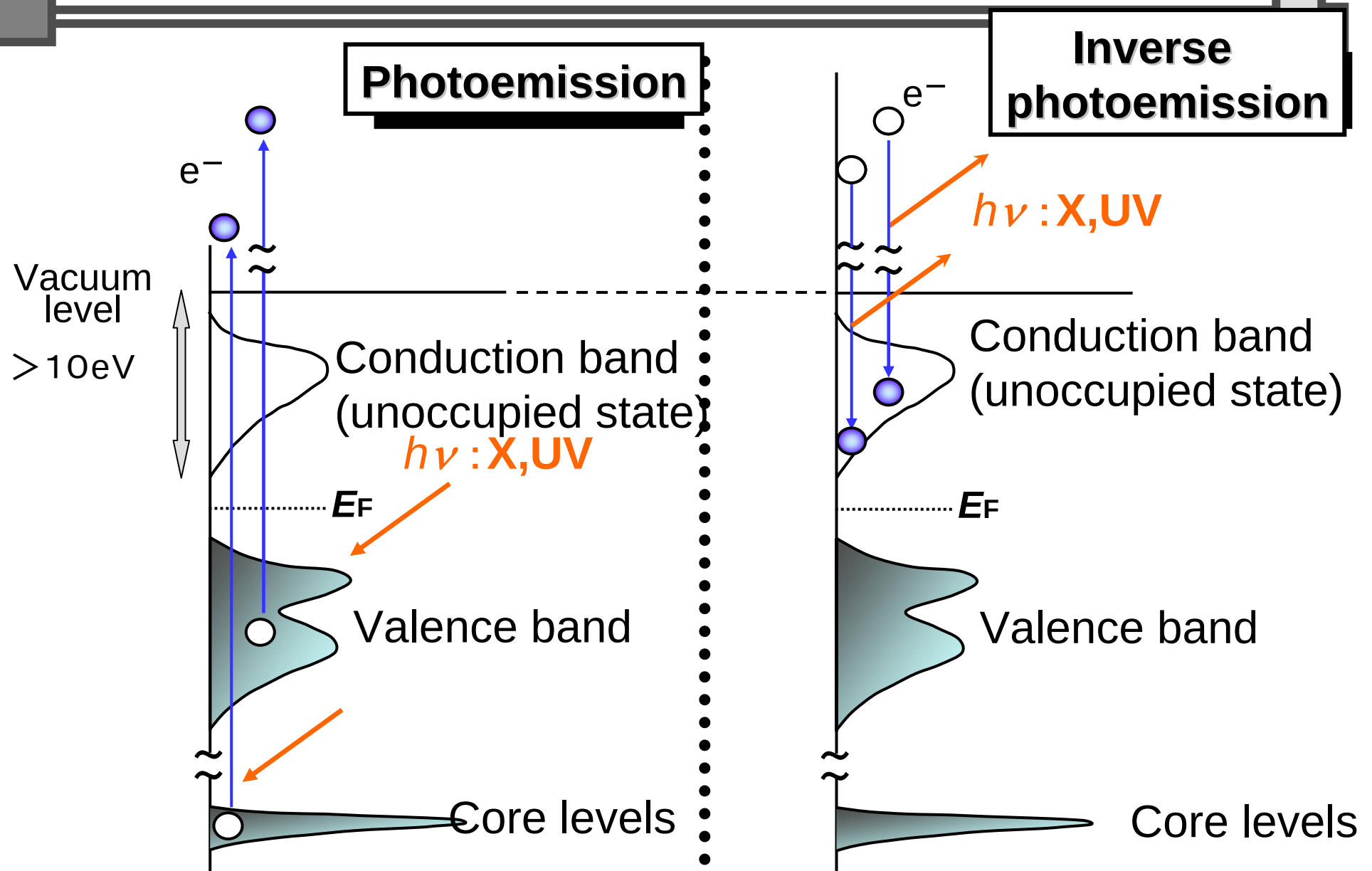


Photoemission Spectroscopy: Principles and application

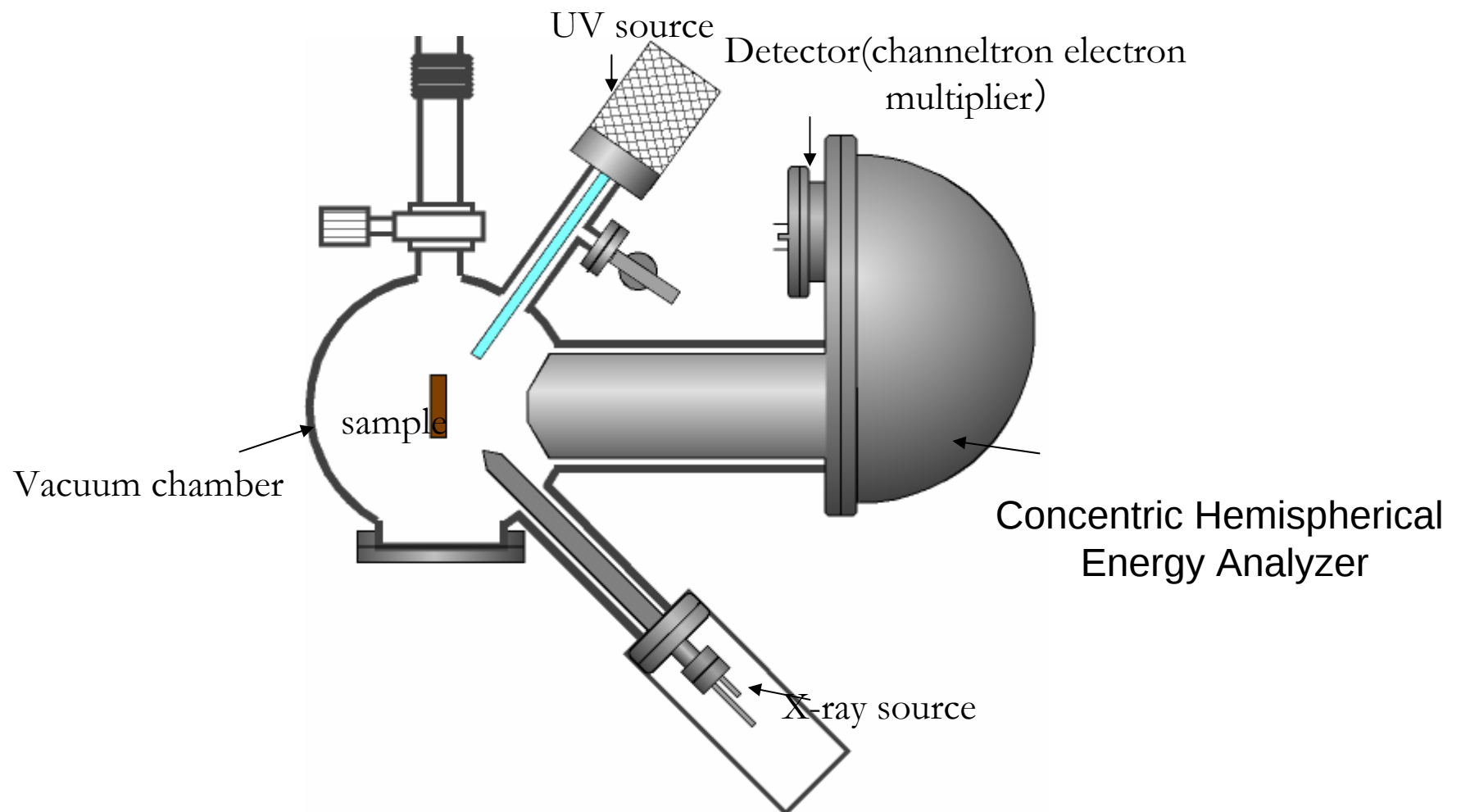


Hideo HOSONO
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Tokyo Institute of Technology, Yokohama, JAPAN

Principle



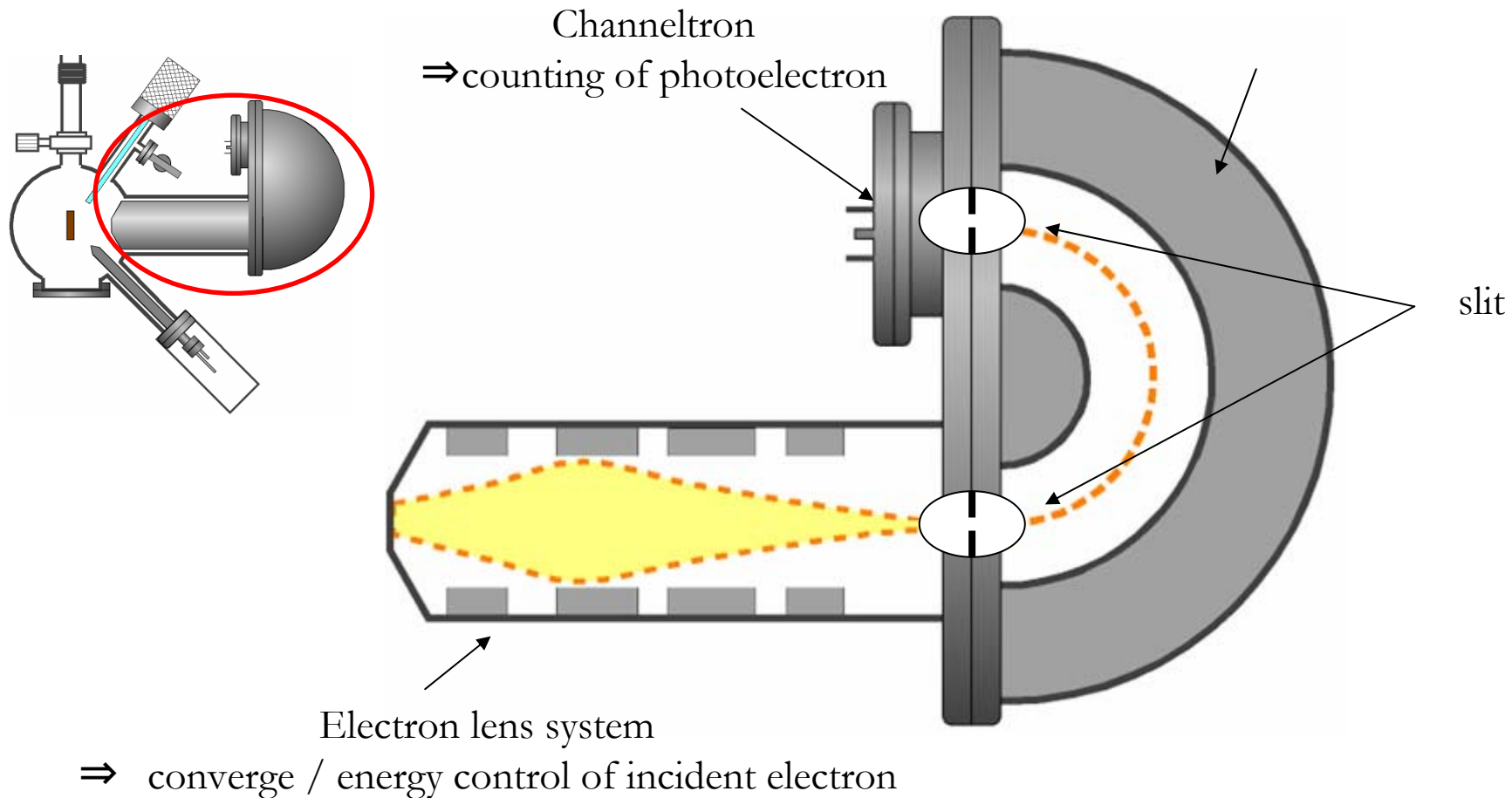
Apparatus



Energy Analyzer (CHA-type)

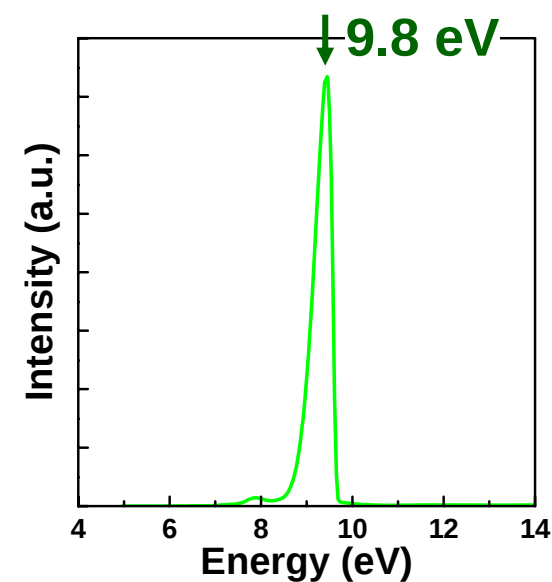
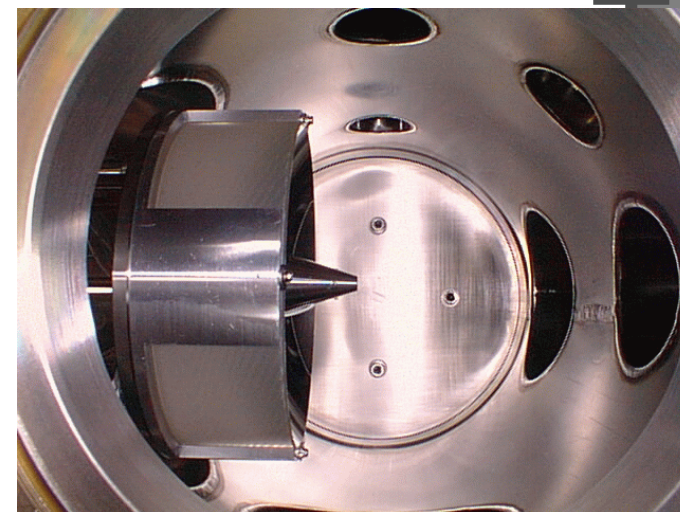
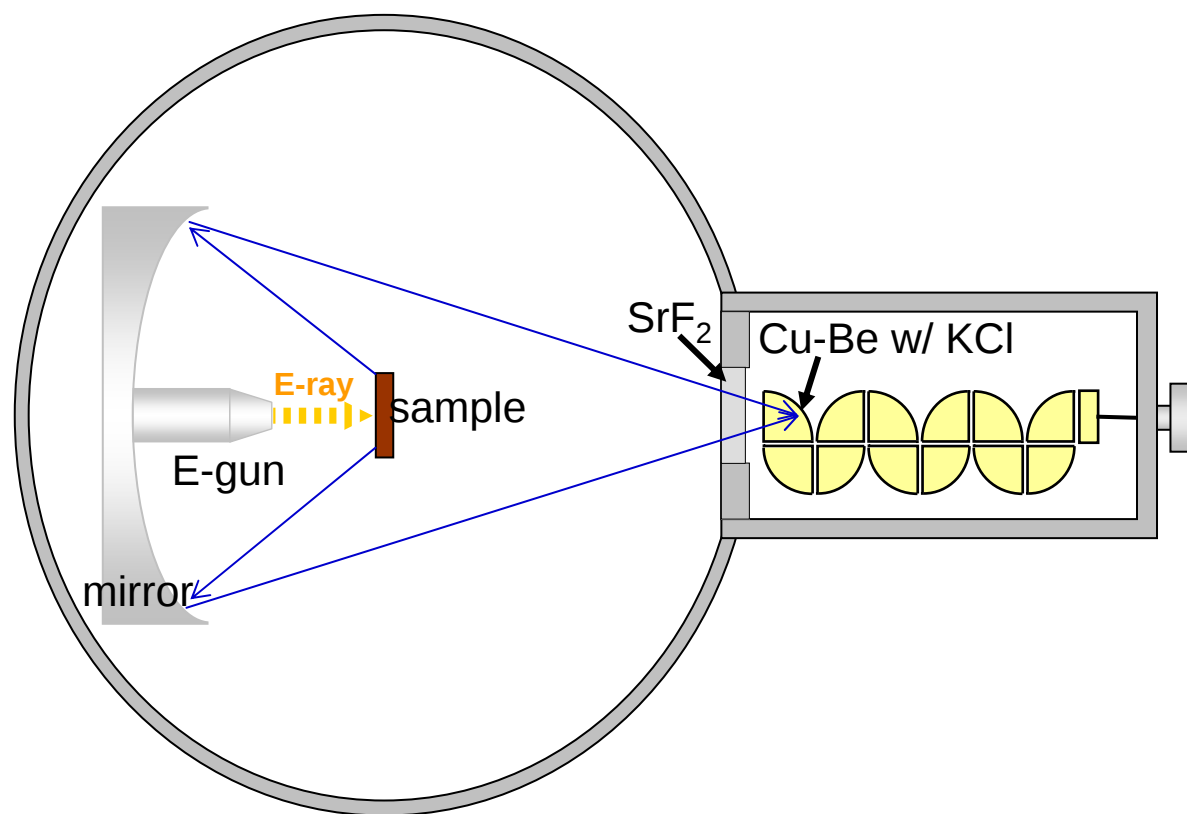
Concentric Hemispherical
Energy Analyzer

⇒ analysis of electron energy



Inverse photoemission Apparatus (BIS mode)

UHV chamber ($\sim 10^{-8}$ Pa)



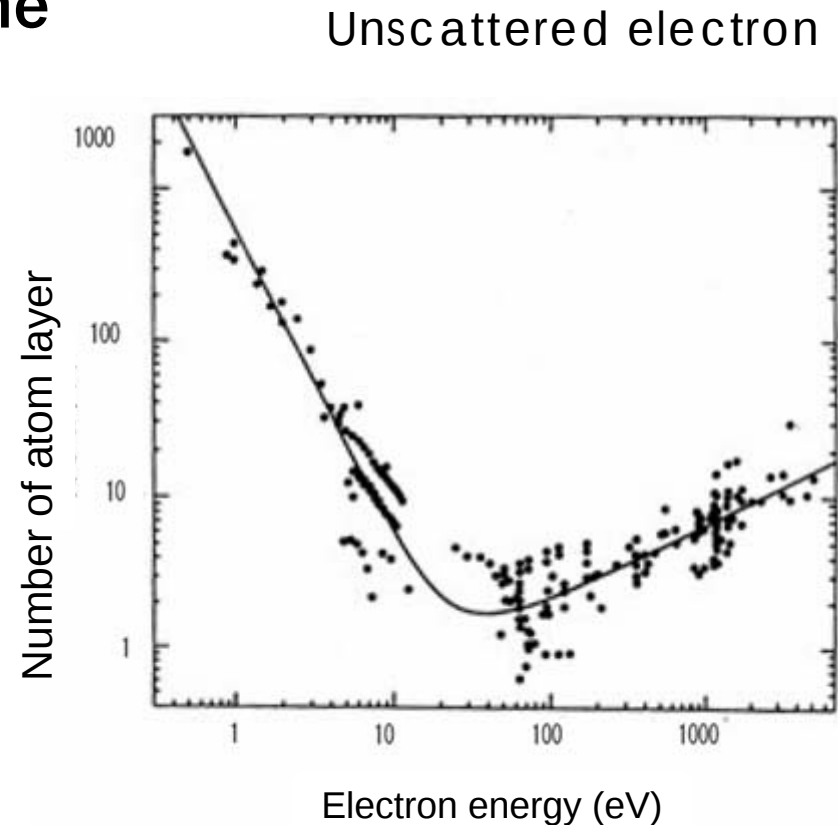
Sample preparation

■ Clean surface is indispensable !

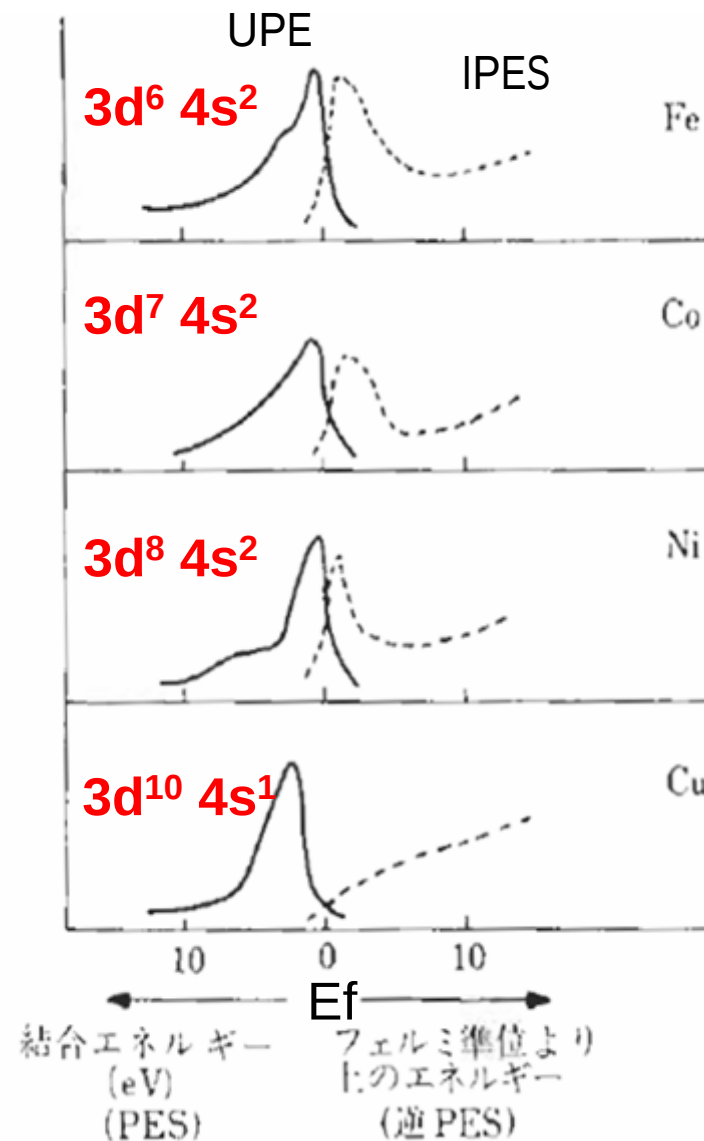
⇒ electron escape depth is limited to below 1-2 nm from the top surface

○ bulk sample : cleavage, filing

○ thin film : ion sputtering

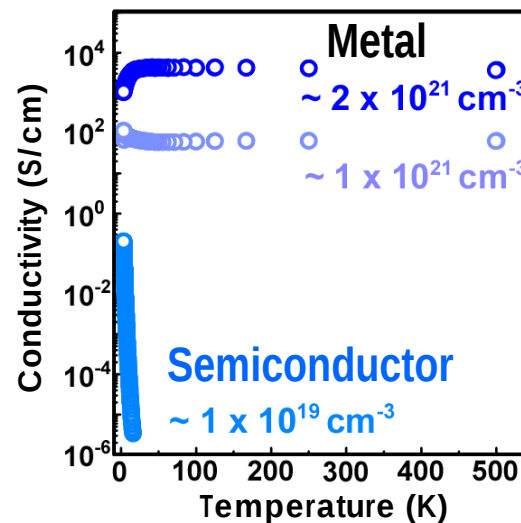
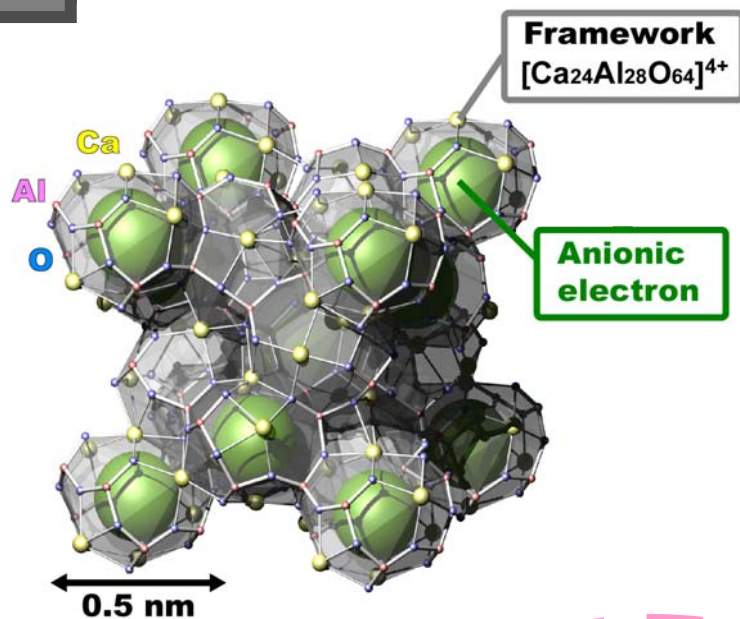


Example (UPS + IPE)

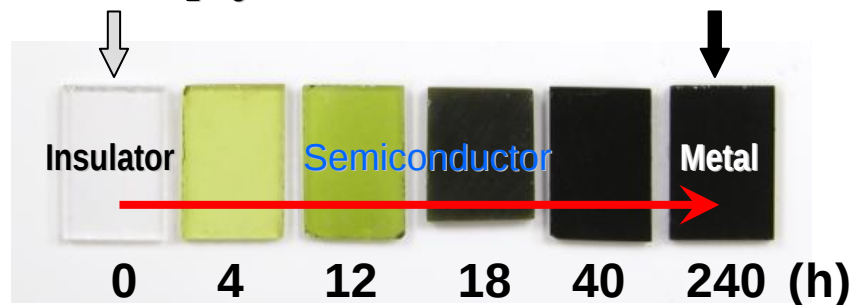


P.A. Cox
The Electronic Structure and
Chemistry of Solids (Oxford)

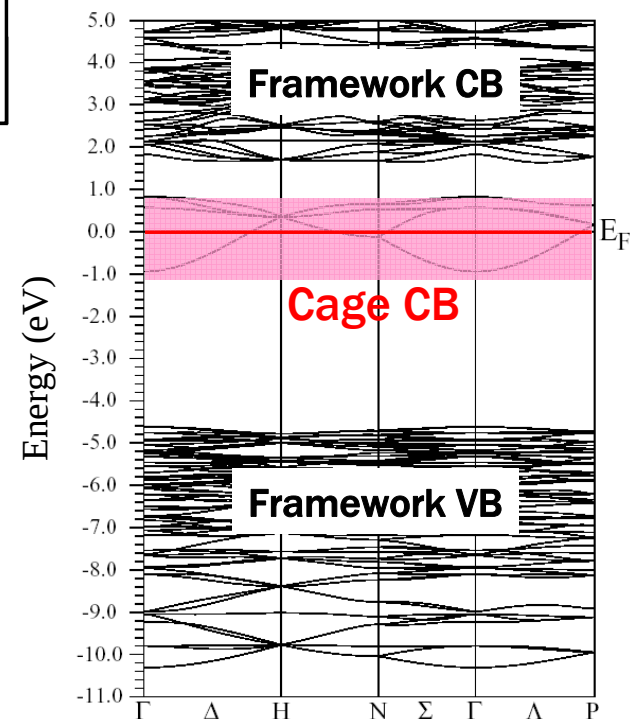
What is C12A7 electrified?



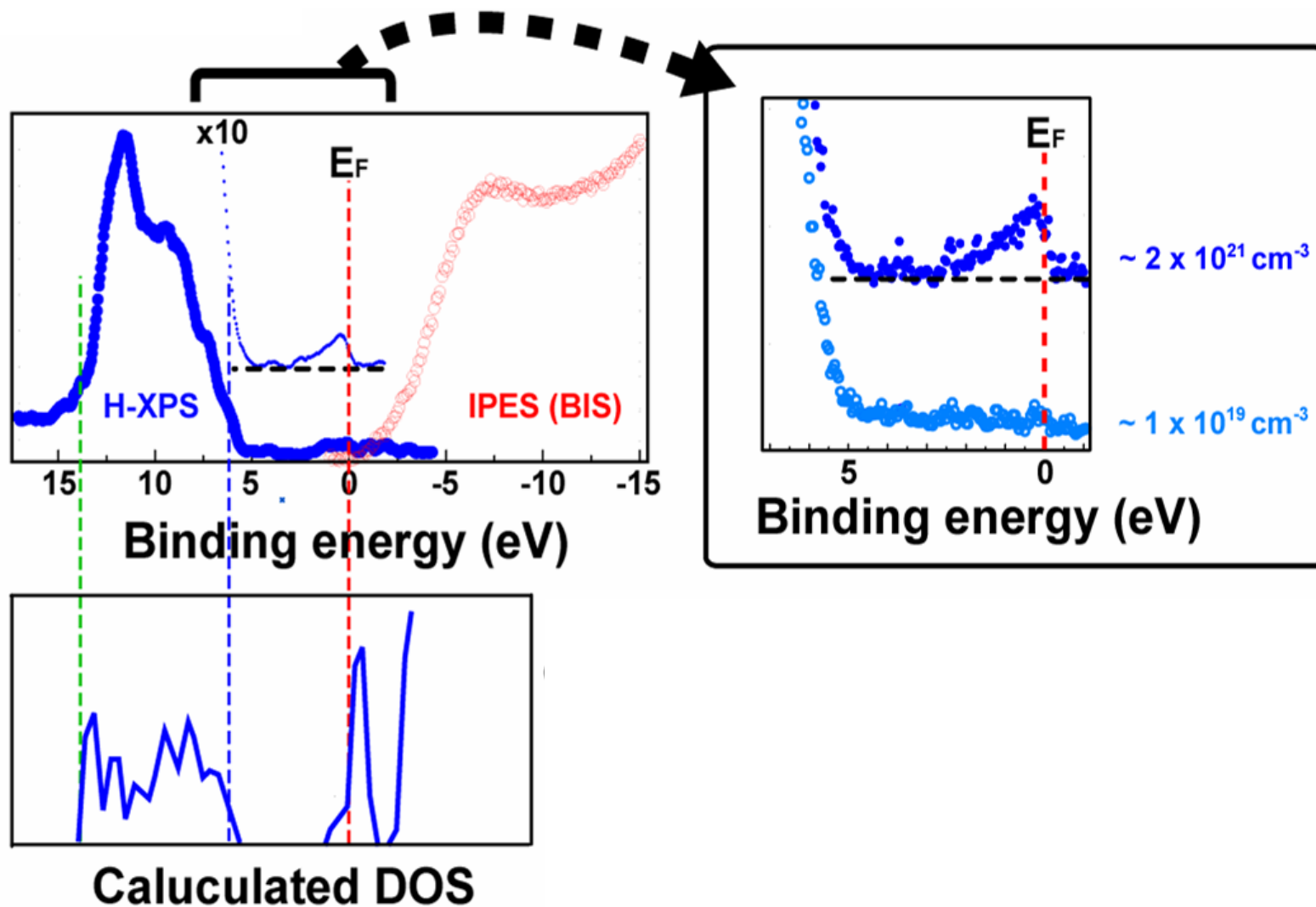
Maximum density
← 1 electron
3 cages



Reduction Time



Observation of Cage CB by HAXPES



P. V. Sushko et al. *J. Am. Chem. Soc.*
129 924-951 (2007)

Xe (I) 8.4 eV UV source

